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APPLICATION NO.	FI	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/955,712	09/955,712 09/19/2001		Vladimir M. Shalaev	37000-0015	1002
5179	7590	03/31/2003			
12		S AND ADAMS P	EXAMINER		
P O BOX 26 ALBUQUEF	6927 ERQUE, NM 871256927			LAVARIAS, ARNEL C	
				ART UNIT	PAPER NUMBER

DATE MAILED: 03/31/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

		<u> </u>
,	Application No.	Applicant(s)
<i>K</i>	09/955,712	SHALAEV ET AL.
Office Action Summary	Examin r	Art Unit
<b>4.</b>	Arnel C. Lavarias	2872
→ The MAILING DATE of this communication ap Period for Reply	op ars on the cov r sh et with the c	correspondence address
A SHORTENED STATUTORY PERIOD FOR REPI THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a rej - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statu - Any reply received by the Office later than three months after the maili earned patent term adjustment. See 37 CFR 1.704(b).  Status	.136(a). In no event, however, may a reply be tin ply within the statutory minimum of thirty (30) day d will apply and will expire SIX (6) MONTHS from te, cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).
1) Responsive to communication(s) filed on 1/5	<u>9/02, 4/8/02, 5/24/02, 9/18/02,2/11</u>	<u>/03</u> .
2a) ☐ This action is <b>FINAL</b> . 2b) ☑ T	his action is non-final.	
3) Since this application is in condition for allow closed in accordance with the practice unde Disposition of Claims		
4)⊠ Claim(s) <u>1-60</u> is/are pending in the application	on.	
4a) Of the above claim(s) <u>2-13,25,26,28,29,3</u>	<u>2-35 and 49-58</u> is/are withdrawn fr	om consideration.
5) Claim(s) is/are allowed.		
6)⊠ Claim(s) <u>1,14-24,27,30,31,36-48,59 and 60</u> is	s/are rejected.	
7) Claim(s) is/are objected to.		
8) Claim(s) are subject to restriction and/	or election requirement.	
Application Papers		
9)⊠ The specification is objected to by the Examin		
10)⊠ The drawing(s) filed on <u>19 September 2001</u> is		•
Applicant may not request that any objection to t	<u> </u>	, ,
11) The proposed drawing correction filed on	_	oved by the Examiner.
If approved, corrected drawings are required in r	• •	
12) The oath or declaration is objected to by the E	examiner.	
Priority under 35 U.S.C. §§ 119 and 120		
13) Acknowledgment is made of a claim for foreign	gn priority under 35 U.S.C. § 119(a	a)-(d) or (f).
a) ☐ All b) ☐ Some * c) ☐ None of:		
Certified copies of the priority documer		
2. Certified copies of the priority documer	• •	
<ul> <li>3. Copies of the certified copies of the pri- application from the International B</li> <li>* See the attached detailed Office action for a lis</li> </ul>	ureau (PCT Rule 17.2(a)).	·
14)⊠ Acknowledgment is made of a claim for domes	tic priority under 35 U.S.C. § 119(	e) (to a provisional application).
a) ☐ The translation of the foreign language poly 15)☐ Acknowledgment is made of a claim for domes	• •	
Attachment(s)		
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Informal i	y (PTO-413) Paper No(s) Patent Application (PTO-152)
S. Patent and Trademark Office		

## **DETAILED ACTION**

## Election/Restrictions

- 1. Applicant's election without traverse of Group III, Claims 14-18, 21, 24, 36, 39, 42, 45, and 48) in Paper No. 9, dated 2/11/03 is acknowledged.
- 2. Claims 2-13,25,26,28,29,32-35 and 49-58 withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to nonelected inventions, there being no allowable generic or linking claim. Election was made **without** traverse in Paper No. 9, dated 2/11/03.

# Specification

3. The disclosure is objected to because of the following informalities:

Page 4, line 4- insert 'one' after 'least'

Page 16, line 18; Page 26, line 23- 'semincontinuous' should read 'semicontinuous'

Page 23, line 15- 'using' should read 'use'

Page 26, lines 14 and 20- 'porous' should read 'pores'

Page 27, line 23- 'white-light' should read 'white-light,'.

Appropriate correction is required.

## Claim Rejections - 35 USC § 102

4. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

5. Claims 1, 19-20, 22-23, 30-31 are rejected under 35 U.S.C. 102(b) as being anticipated by Ducourtieux et al. (S. Ducourtieux et al., "Percolation and fractal composites: Optical studies", J. Nonlinear Optical Physics & Materials, vol. 9, No. 1, 3/2000, pp. 105-116).

With regard to Claim 1, Ducourtieux et al. discloses an optical enhancing material comprising a medium, the medium comprising a semicontinuous metal film of randomly distributed metal particles and their clusters at approximately their percolation threshold (See Page 105, Section 1: Introduction, Page 106, Section 2: Percolation metal-dielectric films: Field distribution and enhanced optical nonlinearities).

With regard to Claims 19-20, 22-23, 30-31, Ducourtieux et al. discloses an optical sensor comprising a medium, the medium comprising a semicontinuous metal film of randomly distributed metal particles and their clusters at approximately their percolation threshold (See Page 105, Section 1: Introduction; Page 106, Section 2: Percolation metal-dielectric films: Field distribution and enhanced optical nonlinearities); a light source incident on the medium; and one or more detectors of light emitted from the medium, the detector detecting a harmonic generation signal (See Section 2, Pages 106-111).

With regard to Claims 59-60, Ducourtieux et al. discloses a sub-femtosecond pulse generation device comprising a medium, the medium comprising a semicontinuous metal film of randomly distributed metal particles and their clusters at approximately their percolation threshold (See Page 105, Section 1: Introduction; Page 106, Section 2:

Percolation metal-dielectric films: Field distribution and enhanced optical nonlinearities); a light source incident on the medium; and one or more near-field detectors of light emitted from the medium (See Section 2.2, Pages 109-111).

6. Claims 1, 19-20, 22-23, 30-31, 43-44, 59-60 are rejected under 35 U.S.C. 102(b) as being anticipated by Shalaev (V. M. Shalaev, "Nonlinear optics of random media: Fractal composites and metal-dielectric films", Springer-Verlag, Berlin, 12/1999).

With regard to Claim 1, Shalaev discloses an optical enhancing material comprising a medium, the medium comprising a semicontinuous metal film of randomly distributed metal particles and their clusters at approximately their percolation threshold (See Pages 1-5; Chapter 5).

With regard to Claims 19-20, 22-23, 30-31, Shalaev discloses an optical sensor comprising a medium, the medium comprising a semicontinuous metal film of randomly distributed metal particles and their clusters at approximately their percolation threshold (See Pages 1-5; Chapter 5); a light source incident on the medium; and one or more detectors of light emitted from the medium, the detector detecting for example a Raman scattering signal (See Pages 134-139).

With regard to Claims 43-44, 46-47, Shalaev discloses an optical switch comprising a medium, the medium comprising a semicontinuous metal film of randomly distributed metal particles and their clusters at approximately their percolation threshold (See Pages 1-5; Chapter 5); a light source incident on the medium, and a layer of optical switching material in the form of particles (See Pages 135-136, particularly the section regarding

local nano-photomodification of percolation films wherein the local field intensity is switched to a different state after photomodification).

With regard to Claims 59-60, Shalaev discloses a sub-femtosecond pulse generation device comprising a medium, the medium comprising a semicontinuous metal film of randomly distributed metal particles and their clusters at approximately their percolation threshold (See Pages 1-5; Chapter 5); a light source incident on the medium; and one or more near-field detectors of light emitted from the medium (See Pages 139-141).

#### Claim Rejections - 35 USC § 103

- 7. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 8. Claims 14-18, 21, 24, 27, 36-42, 45, 48 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shalaev (V. M. Shalaev, "Nonlinear optics of random media: Fractal composites and metal-dielectric films", Springer-Verlag, Berlin, 12/1999).

Shalaev discloses the invention as set forth above in Claim 1, except for the material additionally comprising a microcavity or microresonator made of one or materials selected from the group consisting of dielectric and semiconductor materials; the microcavity being selected from the group consisting of spheres, deformed spheres, spheroids, rods, and tubes; the microcavity being a semiconductor laser cavity; the

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medium being located at one or more surfaces of the microcavity selected from the group consisting of inner and outer surfaces; and the medium being an integrated component of the microcavity. However, in a separate chapter regarding fractal aggregate type random nanocomposite films (See Chapter 3), Shalaev discloses the use of such fractal aggregate films in microcavities (See Pages 69-73) wherein lasing emission was experimentally verified utilizing Rhodamine 6G embedded in silver fractal aggregates inside a cylindrical cavity (See in particular Pages 69-70). Since fractal aggregate films and random metal-dielectric films (i.e. percolation composite films) are extremely similar (See Pages 2-4 regarding a discussion on the similarities and differences between aggregate films and random metal-dielectric films), it would have been obvious to one having ordinary skill in the art at the time the invention was made to replace the fractal aggregate film with a random metal-dielectric films (i.e. percolation composite films), and have the film additionally comprise a microcavity or microresonator made of one or materials selected from the group consisting of dielectric and semiconductor materials; the microcavity be selected from the group consisting of spheres, deformed spheres, spheroids, rods, and tubes; the microcavity be a semiconductor laser cavity; the film be located at one or more surfaces of the microcavity selected from the group consisting of inner and outer surfaces; and the film be an integrated component of the microcavity, as taught by Shalaev, for the purposes of enhancing the resonance response and optical nonlinear properties of laser gain media, thus reducing the required concentrations and pumping requirements for these laser gain media.

## Conclusion

9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Arnel C. Lavarias whose telephone number is 703-305-4007. The examiner can normally be reached on M-F 8:30 AM - 5 PM.

The fax phone numbers for the organization where this application or proceeding is assigned are 703-308-7722 for regular communications and 703-308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-1782.

Arnel C. Lavarias March 27, 2003

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